

# Giant Enhancement of Ferroelectricity

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Enormous strains can exist in thin films when one material is deposited on another due to differences in crystal lattice parameters and thermal expansion behavior between the film and the underlying substrate. As a result, the properties of thin films can be dramatically different than the intrinsic properties of the corresponding unstrained bulk materials. Biaxial compressive strain has been used to dramatically enhance the ferroelectric properties of BaTiO<sub>3</sub> thin films. This strain, imposed by coherent epitaxy, can result in a ferroelectric transition temperature nearly 500 °C higher and a remanent polarization at least 250% higher than bulk BaTiO<sub>3</sub> single crystals. This work demonstrates a route to an environmentally benign lead-free ferroelectric for non-volatile memories and electro-optic devices.

To be published in Science

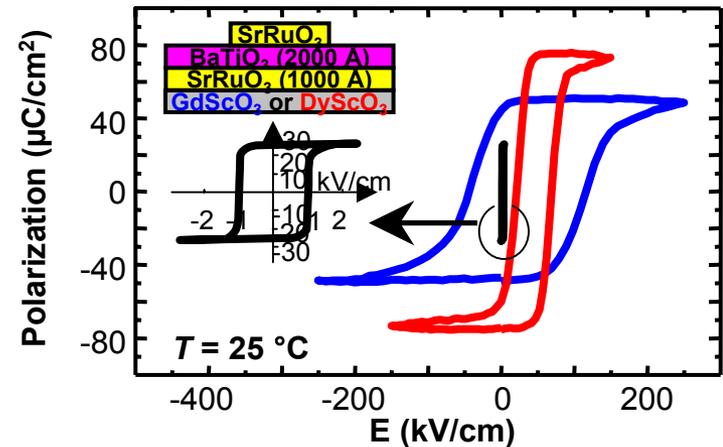


Figure 1. Polarization-electric field hysteresis loops of strained BaTiO<sub>3</sub> thin films and bulk single crystal

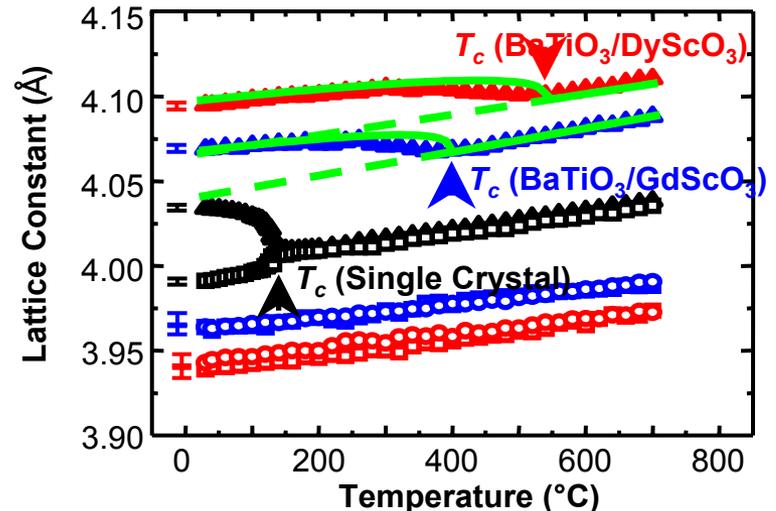


Figure 2. Temperature dependence of the lattice parameters of single crystal BaTiO<sub>3</sub> and strained BaTiO<sub>3</sub> thin films

## Aim of the project:

Strain engineering could facilitate the introduction of more environmentally benign ferroelectric random access memories (FeRAM). Large shifts in the transition temperature ( $T_c$ ) and remanent polarization ( $P_r$ ) are expected and have been observed in ferroelectrics, signaling the viability of a strain-engineered advance for FeRAM. The major disadvantages of the two materials most widely being pursued for FeRAM,  $\text{Pb}(\text{Zr},\text{Ti})\text{O}_3$  and  $\text{SrBi}_2\text{Ta}_2\text{O}_9$ , are (i) the volatility of the lead and bismuth constituents of these materials that complicates their introduction into semiconductor fabrication facilities and (ii) environmental issues associated with the toxicity of lead. We demonstrate that the ferroelectric properties of  $\text{BaTiO}_3$  can be enhanced using strain to make them viable for ferroelectric memory and high speed electro-optic device applications.

## Research results:

Epitaxial  $\text{BaTiO}_3$  thin films were grown on (110)  $\text{GdScO}_3$  and (110)  $\text{DyScO}_3$  substrates which have appropriate lattice constants to impart lattice mismatch of about  $-1.0\%$  and  $-1.7\%$ , respectively, on coherent (001)  $\text{BaTiO}_3$  films.

To identify the ferroelectric phase transition, the temperature dependence of the in-plane and out-of-plane lattice parameters of the films and substrates was measured using a variable-temperature four-circle x-ray diffractometer equipped with a two-dimensional (2-D) area detector. The in-plane and out-of-plane lattice parameters of the strained  $\text{BaTiO}_3$  films are plotted as a function of temperature in Fig. 2. There are striking differences in the evolution of the lattice parameters with temperature between the unstrained  $\text{BaTiO}_3$  single crystal and the strained  $\text{BaTiO}_3$  thin films. Notably, the  $\text{BaTiO}_3$  thin films never become cubic; they remain tetragonal due to the biaxial substrate constraint. Furthermore, The  $T_c$  of the coherent  $\text{BaTiO}_3$  thin films shown in Fig. 2 are  $\sim 400^\circ\text{C}$  on  $\text{GdScO}_3$  and  $\sim 540^\circ\text{C}$  on  $\text{DyScO}_3$ .

Figure 1 shows the ferroelectric hysteresis loops measured on the ferroelectric stacks grown on GdScO<sub>3</sub> and DyScO<sub>3</sub> substrates with 2000 Å thick BaTiO<sub>3</sub> layers, together with results from a BaTiO<sub>3</sub> single crystal. The  $P_r$  and coercive field ( $E_r$ ) were determined to be  $\sim 50 \mu\text{C}/\text{cm}^2$  and 80 kV/cm for the fully coherent BaTiO<sub>3</sub>/GdScO<sub>3</sub> sample and  $\sim 70 \mu\text{C}/\text{cm}^2$  and 25 kV/cm for the partially relaxed BaTiO<sub>3</sub>/DyScO<sub>3</sub> sample, respectively. This  $P_r$  value is almost 270% of the  $26 \mu\text{C}/\text{cm}^2$  of single crystal BaTiO<sub>3</sub>, 250% higher than the switched charge density assumed in the scaling analysis of FeRAM, and comparable to the  $P_r$  of unstrained Pb(Zr,Ti)O<sub>3</sub> films.

Significance of this work:

We have demonstrated that the ferroelectric properties of BaTiO<sub>3</sub> can be dramatically enhanced through strain engineering. These strain-engineered heteroepitaxial thin film provide a broad range of operating temperature as well as higher remanent polarization for improved noise immunity and the ability to scale FeRAM to smaller cell sizes. Another application of strain-engineered BaTiO<sub>3</sub> films is high-speed electro-optic modulators, where the sizeable electro-optic coefficients of BaTiO<sub>3</sub> can be enhanced by appropriate strain engineering. The ability to withstand huge strains gives thin films a degree of freedom absent from bulk. This can be exploited to enhance the ferroelectric properties of any ferroic system, including multiferroics, whose ferroic order parameter has a strong coupling to strain.